

234 REVERSIBLE LOGIC SYNTHESIS OF FAULT TOLERANT CARRY SKIP BCD
STRUCTURAL AND DIELECTRIC PROPERTIES OF $Zn_{1-x-y}Cd_xLi_yO$ SOLID SOLUTION

M. KAMRUZZAMAN^{1*}, M. K. R. KHAN², M. M. RAHMAN², M. SHAHJAHAN², M. A. S. KARAL¹

¹*Department of Physics, Bangladesh University of Engineering and Technology
Dhaka-1000, Bangladesh*

²*Department of Physics, University of Rajshahi, Rajshahi-6205, Bangladesh*

ABSTRACT

$Zn_{1-x-y}Cd_xLi_yO$ ($x=0.30$ and $y=0.05, 0.10, 0.15, 0.20$) have been prepared by solid state reaction method. The prepared samples have been characterized by structural and dielectric measurements. X-ray diffraction (XRD) patterns show a good crystalline nature having double crystal structure and indicates the phase mixing of the constituent components. The hexagonal phase corresponding to ZnO and cubic phase to CdO is well defined and the lattice parameters are consistent with the published values (Grant in Aid report 1987). The estimated lattice parameters, bond length and crystallite size are quite consistent corresponding to the hexagonal ZnO and cubic CdO which suggests the formation of super lattice structure of the system. Crystallite size at different crystallographic planes analyzed from XRD for both ZnO and CdO lie between (15-50) nm. The variation of the dielectric constant of the samples with frequency is systematic and the dielectric constant increases with the increase of Li in the solution.

INTRODUCTION

Electronic materials are extremely important type of materials for advanced science and technology. Microelectronic devices have made possible, by new products of electronic materials such as communication satellites, advanced computers, hand-held calculators, digital watches etc. ZnO and CdO have high transparency in the visible and near infrared region of the electromagnetic spectrum and show n-type conductivity, mainly due to oxygen deficiency and lattice defects. With a band gap ranging 2.2-2.7 eV⁽¹⁾, CdO has a direct band gap of 2.3 eV⁽²⁾ and presents the advantage of a low resistivity with respect to the high values obtained for ZnO, but this exhibits a higher transparency, having a band gap of ~3.2 eV.

Obviously, it is difficult to obtain a high transmission coefficient in the visible region and conductivity qualities simultaneously⁽³⁾, however, a ternary compound which combines these properties in a controlled way may allow the optimization of the window layer. Since ZnO shows ultra-violet excitonic emission at room temperature, therefore it has attracted enormous interests for its potential opto-electronic applications Light Emitting Diode (LED) and Laser Diode (LD) in ultra-violet or blue spectral⁽⁴⁻⁶⁾. It is also used in solar cell and transducer. ZnO is of hexagonal wurtzite-type structure and an excitonic binding energy of ~60 meV, much larger than ~25 meV, which permits the efficient excitonic stimulated ultra-violet emission even at room temperature⁽⁷⁻⁸⁾. To achieve applicable ZnO sample-based opto-electronic devices, there have been considerable experimental investigations focused on the preparation of p-type ZnO sample and its band gap engineering by impurity doping and various alloying methods⁽⁹⁻¹⁰⁾.

To date, a various means of oxide alloying with ZnO samples in thin film form have been investigated but to our knowledge there are no such reports in bulk form. Considering immense application of ZnO in fabrication of devices mentioned above, our aim is to prepare highly conducting ZnO bulk samples by solid state reaction method. Motivated with these facts, we are investigating the effect of Cd ($x=0.30$) and Li ($y=0.05, 0.10, 0.15$ and 0.20) doped ZnO samples by studying structural and dielectric properties.

EXPERIMENTAL

The materials used in the preparation of the samples with analytical grade were ZnO, CdCO₃ and Li₂CO₃. All the materials were procured from local market. Thus $Zn_{1-x-y}Cd_xLi_yO$ ($x=0.30$; and $y=0.05, 0.10, 0.15, 0.20$) were prepared by solid state reaction method.

* Author for Correspondence : mkzaman_phybuet@yahoo.com

XRD patterns of the samples were taken using an X-ray diffractometer at the Department of Electrical and Electronic Engineering, Toyohashi University of Technology, Japan, to check the status and homogeneity. The lattice parameters of the samples were calculated by Hess-Lipson method.

(i) Lattice parameters calculation by Hess-Lipson method:

The interplanar spacing d_{hkl} for the hexagonal system with diffraction angle θ is given as

$$\frac{1}{d_{hkl}^2} = \frac{4}{3} \frac{h^2 + hk + k^2}{a^2} + \frac{l^2}{c^2} \tag{1}$$

where, the wavelength (λ) of X-ray was used 1.5405 Å [CuK α line]

$$\frac{4 \sin^2 \theta_{hkl}}{\lambda^2} = \frac{4}{3} \frac{h^2 + hk + k^2}{a^2} + \frac{l^2}{c^2} \tag{2}$$

$$\sqrt{\sin^2 \theta_{hkl}} = XA + I^2 C \tag{3}$$

where, $X = h^2 + hk + k^2$ (4)

$$A = \lambda^2/3a^2 \tag{5}$$

$$C = \lambda^2/4c^2 \tag{6}$$

and

$$\sin^2 \theta_{100} = A \quad \sin^2 \theta_{010} = A \quad \sin^2 \theta_{001} = C$$

$$\sin^2 \theta_{200} = 4A \quad \sin^2 \theta_{020} = 4A \quad \sin^2 \theta_{002} = 4C \tag{7}$$

$$\sin^2 \theta_{300} = 9A \quad \sin^2 \theta_{030} = 9A \quad \sin^2 \theta_{003} = 9C$$

$$\sin^2 \theta_{110} = 3A \quad \sin^2 \theta_{220} = 12A \quad \sin^2 \theta_{330} = 27A \text{ and so on.}$$

Using relation (7) in equations (5) and (6), we have calculated lattice parameters a and c for hexagonal phase.

The interplanar spacing d_{hkl} for the cubic system with diffraction angle θ is given as

$$\frac{1}{d_{hkl}^2} = \frac{h^2 + k^2 + l^2}{a^2} \tag{8}$$

$$\sqrt{\sin^2 \theta_{hkl}} = \lambda^2/4a^2 (h^2+k^2+l^2) \tag{9}$$

Again, using relation (7) in equation (9), we have also calculated lattice parameter, a for cubic phase.

The Zn-O bond length has been calculated by the relation⁽¹¹⁾.

$$\sqrt{\frac{a^2}{3} + \frac{a^2}{6} - u^2 c^2}$$

where, $u = a^2/3c^2 + 0.25$, u is the positional parameter of hexagonal structure. The d_{hkl} values of the $Zn_{1-x-y}Cd_xLi_yO$ are shown in the Tables 1-4.

(ii) Calculation of crystallite size:

The XRD patterns clearly indicate that the samples are of crystalline type, the reflection line profiles were subjected to calculate crystal or grain size perpendicular to the different crystallographic planes. The crystallite size, x , of the samples were determined quantitatively using the formula⁽¹²⁾.

$$x = \frac{\kappa l}{B \cos \theta}$$

where, l is the wavelength of the incident X-ray beam κ is a constant equal to unity and θ is Bragg angle. In general, B is full width at half-maximum (FWHM) of a diffraction peak expressed in radians.

(iii) Calculation of dielectric constant:

The dielectric constants were calculated from the capacitance, measured at room temperature by Precision Impedance Analyzer, Model, Agilen 429 A (40 Hz-110 MHz) using the relation

$$\hat{\epsilon} = \frac{C \cdot d}{\hat{\epsilon}_0 A}$$

where, C is the capacitance, d is the thickness, A is the area of the sample and $\hat{\epsilon}_0$ is the permittivity of the free space.

RESULTS AND DISCUSSION

The XRD patterns for $Zn_{1-x-y}Cd_xLi_yO$ are shown in Fig.1

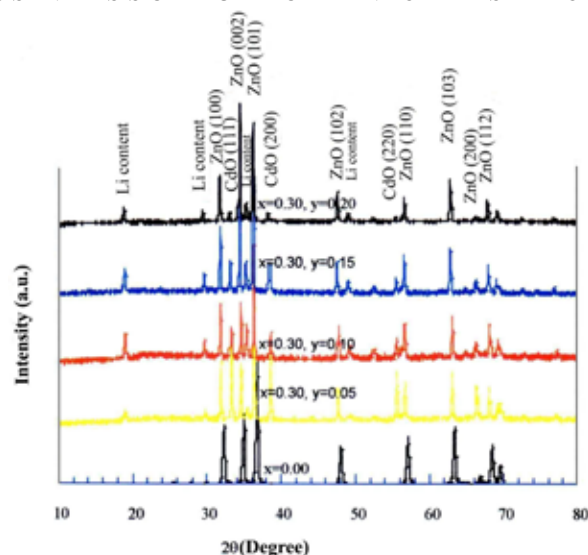


Fig. 1. XRD pattern for $Zn_{1-x-y}Cd_xLi_yO$

It is seen that all samples are very good crystalline in nature and preferentially oriented. The different peak positions oriented in the different crystallographic planes of synthesized samples are tabulated in Tables 1-4. The diffraction pattern was collected for 2θ values in the scattering range (10-80) degree for $Zn_{1-x-y}Cd_xLi_yO$. For pure ZnO, diffraction peaks identified as (1 0 0), (0 0 2), (1 0 1), (1 0 2), (1 1 0), (1 0 3), (2 0 0) and (1 1 2) planes. There are three distinct peaks at around angles (2θ values) 33.26° , 38.58° and 55.54° , correspond to planes (1 1 1), (2 0 0) and (2 2 0) appeared in addition to the ZnO peaks. Analyzing the peak positions of the spectrogram with standard JCPDS cards both for ZnO and CdO, it is clear that the spectrogram is the combination of two crystal structures-one for hexagonal ZnO and other for cubic CdO. Considering these two structures, the lattice parameters were found consistent with reported values for both structures. The lattice parameters, bond length, crystal volume and a/c ratio for ZnO are tabulated in Table 5. The reference values of lattice parameters, a and c for ZnO from JCPDS cards are, $a = 3.24982 \text{ \AA}$, $c = 5.20661 \text{ \AA}$. The lattice parameters determined in this study for cubic CdO is 5.359 for (2 0 0) plane. There are also four extra peaks found at around 20° , 30° , 35° and 50° for Li content phase. The intensity of these extra peaks increases with the increase of Li in the solution.

Table1.
The d_{hkl} values of $Zn_{1-x-y}Cd_xLi_yO$ ($x=0.30, y=0.05$)

Peak No.	2θ (degree)	d_{hkl} (\AA) expt.	d_{hkl} (\AA) (from JCPDS)	Intensity (%) expt	Standard Miller indice (hkl)	Possible phase	Crystallite size, ξ (nm)
1	18.80	4.7160	-	22	-	Li content	27
2	29.58	3.015	-	15	-	Li content	39
3	31.79	2.8124	2.8140	49	1 0 0	ZnO	44

4	33.12	2.7024	2.7120	65	1 1 1	CdO	44
5	34.44	2.601	2.6030	46	0 0 2	ZnO	47
6	36.27	2.4776	2.4759	100	1 0 1	ZnO	42
7	38.40	2.3421	2.3490	58	2 0 0	CdO	35
8	47.53	1.9113	1.9111	28	1 0 2	ZnO	35
9	55.42	1.6564	1.6610	40	2 2 0	CdO	34
10	56.56	1.6257	1.6247	31	1 1 0	ZnO	33
11	62.82	1.4779	1.4772	38	1 0 3	ZnO	32
12	66.04	1.413	1.4072	28	2 0 0	ZnO	25
13	68.88	1.3619	1.3782	32	1 1 2	ZnO	33

Table 2.
The d_{hkl} values of $Zn_{1-x}Cd_xLi_yO$ ($x=0.30$, $y=0.10$)

Peak No.	2θ (degree)	d_{hkl} (Å) expt	d_{hkl} (Å) (from JCPDS)	Intensity (%) expt	Standard Miller indices (hkl)	Possible phase	Crystallite size, ξ (nm)
1	18.80	4.7160	-	22	-	Li content	28
2	29.51	3.018	-	15	-	Li content	39
3	31.74	2.8167	2.8120	49	1 0 0	ZnO	42
4	33.08	2.6496	2.6600	29	0 0 2	ZnO	49
5	35.24	2.5445	-	30	-	Li content	35
6	36.22	2.4777	2.4759	100	1 0 1	ZnO	44
7	38.36	2.3444	2.3490	25	2 0 0	CdO	38
8	47.48	1.9132	1.9111	29	1 0 2	ZnO	46
9	49.00	1.8573	-	11	-	Li content	23
10	55.40	1.6570	1.6610	17	2 2 0	CdO	38
11	56.52	1.6268	1.6247	30	1 1 0	ZnO	33

12	62.77	1.4790	1.4771	37	1 0 3	ZnO	30
13	67.86	1.3799	1.3782	29	1 1 2	ZnO	33

Peak No.	2θ (degree)	d _{hkl} (Å) expt	d _{hkl} (Å) (from JCPD)	Intensity (%) expt	Standard Miller indices(hkl)	Possible phase	Crystallite size, ξ (nm)
1	18.80	4.7196	-	19	-	Li content	26
2	29.56	3.019	-	15	-	Li content	30
3	31.80	2.8115	2.8140	52	1 0 0	ZnO	38
4	33.16	2.6992	2.7120	25	1 1 1	CdO	42
5	34.48	2.5989	2.6030	72	0 0 2	ZnO	44
6	35.31	2.539	-	25		Li content	32
7	36.30	2.4726	2.4759	100	1 0 1	ZnO	38
8	38.45	2.3392	2.3490	23	2 0 0	CdO	40
9	47.56	1.9102	1.9111	39	1 1 2	ZnO	35
10	49.81	1.7850	-	23	- -	Li content	2928
11	55.47	1.6570	1.6610	12	2 2 0	CdO	3339
12	56.47	1.6254	1.6247	30	1 0 0 2	ZnO	3344
13	56.72	1.5449	1.4160	27	2 0 0	ZnO	5032
14	67.92	1.3788	1.3782	20	1 1 2	ZnO	26
15	36.20	2.4792	2.4759	85	1 0 1	ZnO	40
16	38.40	2.3421	2.3490	7	2 0 0	CdO	42
17	47.47	1.9136	1.9111	27	1 0 2	ZnO	29
18	56.49	1.6276	1.6247	20	1 1 0	ZnO	26
19	62.76	1.4792	1.4771	37	1 0 3	ZnO	20
20	66.04	1.413	1.4072	28	2 0 0	ZnO	25

Table 3.
The d_{hkl} values of Zn_{1-x}-Cd_xLi_yO (x=0.30, y=0.15)

Table 4.
The d_{hkl} values of Zn_{1-x}-Cd_xLi_yO (x=0.30, y=0.20)

13	68.88	1.3619	1.3782	18	1 1 2	ZnO	28
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Table 5.

Lattice
bond
a/c ratio of
 ${}_y\text{Cd}_x\text{Li}_y\text{O}$
from XRD

We have

$\text{Zn}_{1-x-y}\text{Cd}_x\text{Li}_y\text{O}$	Lattice constant of ZnO (Å)		Bond length (Å)	Bond length (Å) for ZnO ⁽¹¹⁾	Volume of ZnO (Å ³)	a/c ratio
	a	c				
x=0.0, y=0.0	3.1950	5.2240	1.877	1.877	46.152	0.6111
x=0.30, y=0.05	3.2447	5.202	1.9762	1.9778	47.507	0.6242
x=0.30, y=0.10	3.2524	5.2992	1.9902		48.544	0.6137
x=0.30, y=0.15	3.2464	5.1978	1.9753		47.439	0.6245
x=0.30, y=0.20	3.2539	5.208	1.9796		47.752	0.6247

constants,
length and
 Zn_{1-x} -
estimated

calculated crystallite size for ZnO and CdO in different crystallographic planes and tabulated in Tables 6 and 7. The values obtained are consistent with the estimated values⁽¹³⁾.

Table 6.

Crystallite size of ZnO at different (hkl) planes for $\text{Zn}_{1-x-y}\text{Cd}_x\text{Li}_y\text{O}$

Table.7
Crystallite size of CdO at different (hkl) planes for Zn_{1-x-y}Cd_xLi_yO

The dielectric constant of Zn_{1-x-y}Cd_xLi_yO was calculated from measured values of the capacitances. Fig.2 shows the variation of dielectric constant with frequency at room temperature. The dielectric constant is found high at lower frequency and low at higher frequency regions. It increases with the increase of Li in the solution.

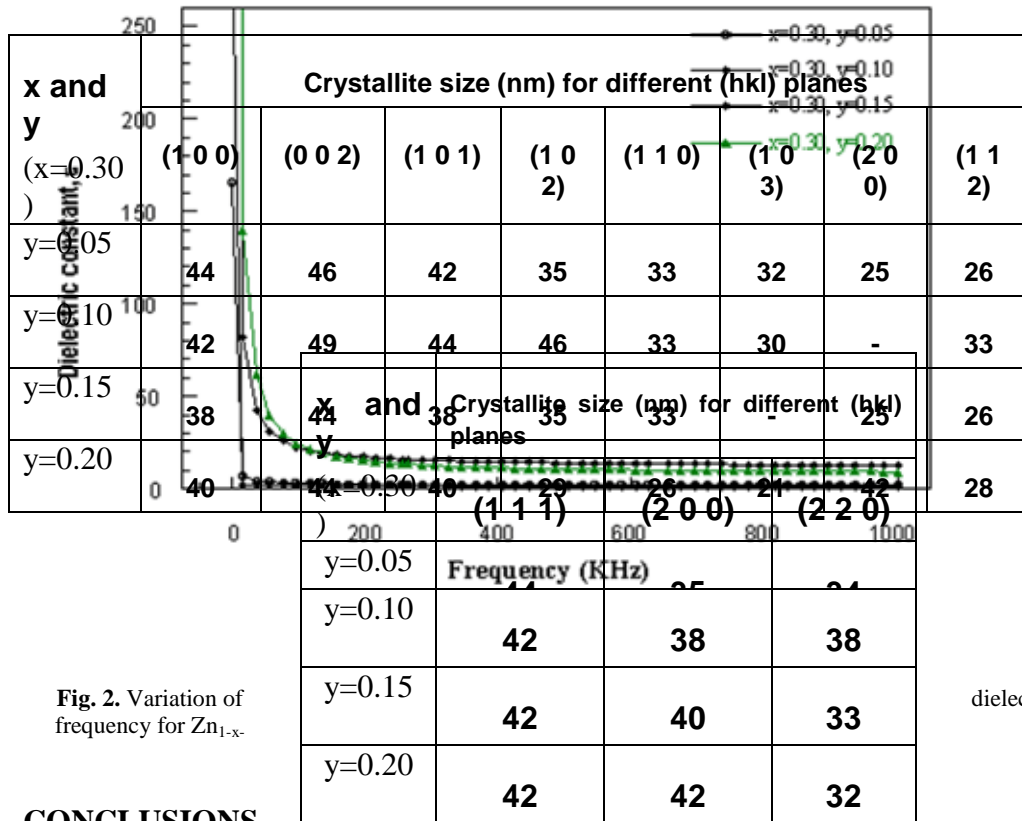


Fig. 2. Variation of dielectric constant with frequency for Zn_{1-x-y}Cd_xLi_yO

CONCLUSIONS

From the XRD analysis, it is clear that there exists hexagonal ZnO and cubic CdO phase in the Zn_{1-x-y}Cd_xLi_yO. The estimated lattice parameters, bond length and crystallite size are quite consistent corresponding to the hexagonal ZnO and cubic CdO crystals which suggests the formation of super lattice structure of the system. The variation of the dielectric constant of the samples with frequency is systematic and also the dielectric constant increases with the increase of Li in the solution.

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